



# **CSTIC 10 Year Anniversary**

# 十年纪念 Committee & Semi China Teams

Prepared by David Huang. March 2019

# **CSTIC 10 Year Anniversary**



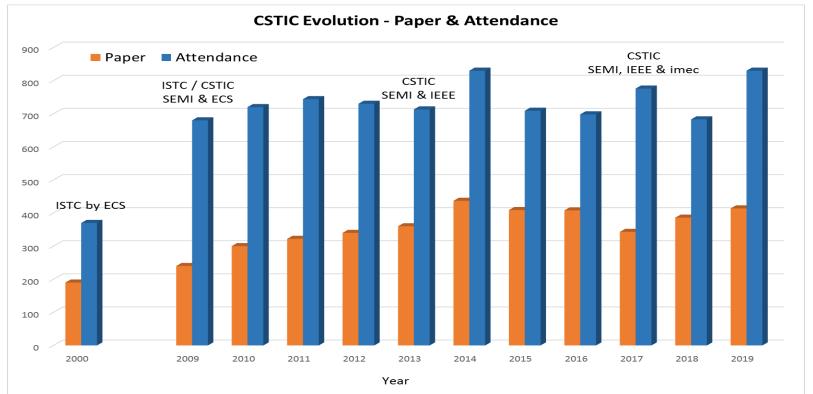
- CSTIC was initiated in 2009 with Semi and ECS as the organizers, source from ISTC (since 2000), and tested as CSMIC (2008). A Semiconductor technical forum to bridge China and the World. Volunteer committee team, open, transparent, passion.
- Influential conference. Papers from 230 to 400, attendee from 300 ~800, nine symposia to cover the IC manufacturing flow, ~80 committee members around the World. Panel discussions, training, poster... International organizers: Semi, imec, IEEE.
- Focus on manufacturing technology, speakers from: Intel, Samsung, TSMC, Global Foundries,
   SMIC, imec, AMAT, TEL, Stanford, MIT, Beijing University....
- Distinguished plenary speakers: Four Nobel Laureate speakers so far: Georg Bednorz (2009),
   Leo Esaki (2011), Ivar Giaever (2013), <u>Hiroshi Amano (2017)</u>, VP or fellow from Intel, TSMC, IBM,
   SMIC, Huawei. Excellent invited speakers from established world class experts.
- Together, we continuously work with industry in semiconductor golden period & region





#### **CSTIC – IC Manufacturing Technology Forum**









# 2008, Warm Up as CSMIC, Shanghai, Intercontinental Hotel

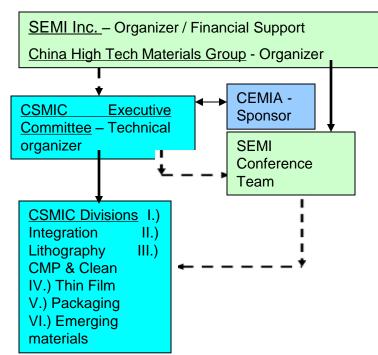






SEMICON'

## CSMIC 2008 Technical Committee 大会技术委员会 \_\_\_\_



CSMIC technical committee consists of area experts and they are all volunteers like other major technical conferences in the world

				2010
Conference Executive Committee				
Dr.	David Huang	黄丕成	Chairman	Director, Praxair Inc., USA.
Mrs.	Shi Ying	石瑛	Co-Chair	Director, Gritek,China
Dr.	Hanming Wu	吴汉明	Co-Chair	Technical Director, SMIC, China
Dr.	Qingyuan Han	韩清源	Co-Chair	President, Hans Consultanting, USA
Mrs.	April Peng	彭晔	Secretary	Chief Editor, Semi China
Session I. New Materials and Process Integration				
Dr.	Hanming Wu	吴汉明	Chairman	Technical Director, SMIC, China
Dr.	Youfan Lui	刘友凡	Co-Chair	Chairman, CASPA Phenix USA
Session II. Photolithography				
Dr.	Cindy Chen	陈昕	Chairperon	President, Kempur, China
Dr.	Curtis Liang	梁强	Co-chair	Manager, ASML-China
Session III. CMP & Cleaning				
Dr.	Chris Yu	俞昌	Chairman	CEO, Anji Microelectronics
Dr.	Kuochun Wu	吴国俊	Co-chair	Director, Cabot Micorelectonics Inc
Session IV. Thin Film, Etch and Plating				
Dr.	WeiE Wang	王维一	Chairman	Scientist, Intel Inc
Dr.	Fei Xue	徐飞	Co-chair	Director, ATMI Inc.
Session V. Packaging Materials				
Dr.	Wei Chen	陈维	Chairman	Manager, Dow Corning, China
Mr.	Han Jianglong	韩江龙	Co-chair	President, Henkel Huawei, China
Session VI. Emerging and Special Materials				
Dr.	Qinghuang Lin	林庆煌	Chairman	Scientist, IBM, USA.
Dr.	Renhe Jia	贾仁合	Co-chair	Sr. Engineer, Applied Materials, USA





#### Scope of the Conference



China Semiconductor Technology International Conference - CSTIC

中国半导体技术国际会议

Device Design 晶片设计

- layout materials requirement

提出对材料的构想

<u>Processes 工艺流程</u> - Integrate the materials

组合材料

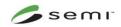
Materials 材料

- Basic elements to form a device Fundamental 基础研究 Manufacturing 制造生产

Application 工业应用

Tooling 设备装置
- Plate form to integrate materials
材料组合的平台





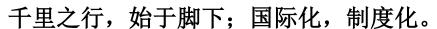
2009, Initiated CSTIC from ISTC with Semi & ECS, Sheraton







**FPDCHINA** 





#### 2010, Good Speakers, Nice Team























#### 2012, Understand Quantum Tunneling









2013 – Introduction of IEEE, EI Searchable.









**FPDCHINA** 

Moved to SHICC 2014,







2015, Consistently Focus on Manufacturing Technology











2016, Post Moore's Law - What will be the path?







2019

# 2017, Partner with imec. Memory Chip Market Booming









#### 2018, EUV, FinFET Enabled Sub 10nm Node







**FPDCHINA** 





#### CSTIC 2019, 2029, 39... Technology is Driving Industries









Data centers / IoT

**5G Network / Devices** 

**Artificial Intelligence** 







semi innec �IEEE

**IC Chip Essential** 

中国国际半导体技术大会(CSTIC)



